

Title (en)

METHOD FOR FABRICATION OF A CROSS-POINT MEMORY

Title (de)

VERFAHREN ZUR HERSTELLUNG EINES KREUZPUNKTSPEICHERS

Title (fr)

PROCÉDÉ DE FABRICATION D'UNE MÉMOIRE À POINTS DE CROISEMENT

Publication

**EP 3111488 B1 20200722 (EN)**

Application

**EP 15755629 A 20150209**

Priority

- US 201414189490 A 20140225
- US 2015015023 W 20150209

Abstract (en)

[origin: US2015243708A1] The disclosed technology relates generally to integrated circuit devices, and in particular to cross-point memory arrays and methods for fabricating the same. In one aspect, a method of fabricating cross-point memory arrays comprises forming a memory cell material stack which includes a first active material and a second active material over the first active material, wherein one of the first and second active materials comprises a storage material and the other of the first and second active materials comprises a selector material. The method of fabricating cross-point arrays further comprises patterning the memory cell material stack, which includes etching through at least one of the first and second active materials of the memory cell material stack, forming protective liners on sidewalls of the at least one of the first and second active materials after etching through the one of the first and second active materials, and further etching the memory cell material stack after forming the protective liners on the sidewalls of the one of the first and second active materials.

IPC 8 full level

**H01L 45/00** (2006.01)

CPC (source: EP KR US)

**H10B 63/24** (2023.02 - EP KR US); **H10B 63/80** (2023.02 - EP KR US); **H10N 70/011** (2023.02 - KR); **H10N 70/063** (2023.02 - EP KR US); **H10N 70/20** (2023.02 - EP); **H10N 70/231** (2023.02 - EP KR US); **H10N 70/801** (2023.02 - EP KR US); **H10N 70/826** (2023.02 - EP KR US); **H10N 70/8828** (2023.02 - EP KR); **H10N 70/8833** (2023.02 - EP); **H10N 70/8828** (2023.02 - US)

Cited by

JP2022120027A

Designated contracting state (EPC)

AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

DOCDB simple family (publication)

**US 2015243708 A1 20150827; US 9806129 B2 20171031;** CN 106030842 A 20161012; CN 106030842 B 20200428; CN 111490063 A 20200804; CN 111490063 B 20231114; EP 3111488 A1 20170104; EP 3111488 A4 20171115; EP 3111488 B1 20200722; EP 3742507 A1 20201125; EP 3742507 B1 20230104; JP 2017510983 A 20170413; JP 2018198321 A 20181213; JP 2020145434 A 20200910; JP 6412949 B2 20181024; JP 6708833 B2 20200610; JP 7284728 B2 20230531; KR 101941346 B1 20190122; KR 102061443 B1 20191231; KR 102177030 B1 20201111; KR 20160113188 A 20160928; KR 20190002754 A 20190108; KR 20190143501 A 20191230; SG 10202005386T A 20200729; SG 11201606642T A 20160929; TW 201545332 A 20151201; TW I557891 B 20161111; US 10854674 B2 20201201; US 11600665 B2 20230307; US 2017365642 A1 20171221; US 2021091140 A1 20210325; WO 2015130455 A1 20150903

DOCDB simple family (application)

**US 201414189490 A 20140225;** CN 201580009999 A 20150209; CN 202010312551 A 20150209; EP 15755629 A 20150209; EP 20185833 A 20150209; JP 2016553546 A 20150209; JP 2018140688 A 20180726; JP 2020054015 A 20200325; KR 20167022925 A 20150209; KR 20187038032 A 20150209; KR 20197038026 A 20150209; SG 10202005386T A 20150209; SG 11201606642T A 20150209; TW 104105716 A 20150217; US 2015015023 W 20150209; US 201715693102 A 20170831; US 202017069347 A 20201013